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Michael Veith^a; Andreas Rammo^a; Markus Hans^a

^a Institut für Anorganische Chemie, Universität des Saarlandes, Saarbrücken, Germany

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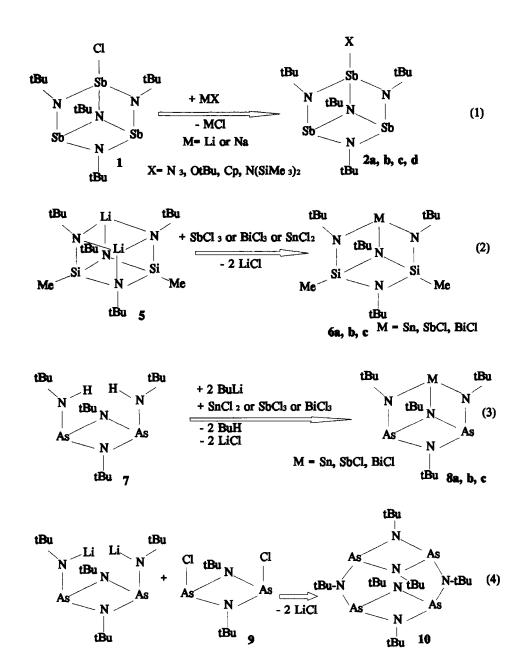
POLYCYCLIC AMIDES AND SILYLAMIDES OF Ge, Sn, As, Sb AND Bi

MICHAEL VEITH, ANDREAS RAMMO AND MARKUS HANS Institut für Anorganische Chemie, Universität des Saarlandes, D-66041 Saarbrücken, Germany

Abstract Polycyclic compounds with nitogen, (silicon, carbon) and metallic main group elements like Ge, Sn, As, Sb and Bi forming the skeleton have been synthesized by two different ways. By a first route the components of the compounds are put together by classical salt elimination reactions while by the second procedure a Lewis acidic center in the molecule (Ge) serves as target for an intramolecular attack of a nitogen base. If this nitrogen atom has an trimethylsilyl substituent a trimethylsilyl migration to the electronegative end of the Ge=X bond (X=O, N-SiMe₃, S) is observed parallel to the Ge-N bond formation; if the nitorgen atom is substituted by tert-butyl, an intramolecularly N-coordinated Ge=X system is isolated as a crystalline compound.

POLYCYCLES WITH A METAL TRICAPPED N.-TETRAHEDRON

As we have shown several years ago the tricyclic Sn₃(NtBu),H₂ can be described as a distorted N.-tetrahedron three of the faces being capped by tin atoms. This compound also shows unique bond fluctuations.2 We have been interested in the synthesis of similar compounds, in order to study parameters more closely which could be responsible for such In equations (1) (4) our attempts properties. summarized. All products (50-85% yield) show analytical and spectroscopic (IR, NMR) data. The chlorine substituent in 1 (which originates from the reaction of SbCl₃ and tert-butylamine besides other products) can be displaced by several ligands to yield 2a, 2b, 2c and 2d. Treatment of 1 with AlCl₃ or SnCl₂ is followed by chloride abstraction from the polycycle yielding the ionic Sb3(NtBu)4 AlCl4 (3) and Sb, (NtBu), SnCl, (4). While in 1, 2, 3 and 4 three



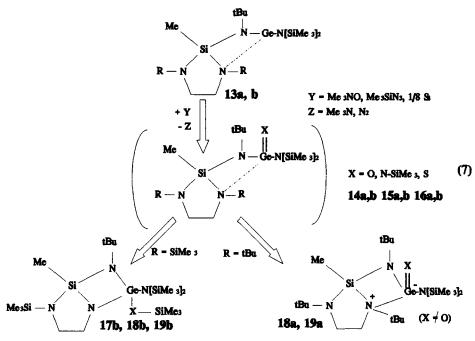
antimon atoms together with the nitrogen atoms form the polycyclic skeleton, in 6 and 8 two of the electropositive sites are occupied by Me-Si or As, which are introduced by the precursors 5^3 and 7^4 [see equations (2) and (3)]. A

remarkable tricyclic compound 10, which displays parallel As_2N_2 rings, is obtained in reaction (4), when the ring compound 9^5 is used as starting material. X-ray structure analyses have made of 1, 2a, 4, $6b*SnCl_2$ and 10.

INTRAMOLECULAR NITROGEN COORDINATION TO UNSATURATED Ge

The ring compounds 11a(R = tBu) and $11b(R = SiMe_3)$ can be synthesized from Me-Si(Cl)₂N(tBu)H and R-N(H)-CH₂CH₂-N(H)-R⁶ by standard techniques. The amino hydrogen atom is then displaced by Ge-Cl following the route described in equation (5) yielding 12a,b. The sterically very demanding

hexamethyldisilzyl ligand is introduced at the germanium atom [13a,b equation (6)] to protect it from immediate polymerisation when the germanium(II) compound is oxidized. X-ray structure determination of 12a reveals a donor acceptor bond from one of the nitogen atoms in the five membered ring to Ge. All oxidation reactions performed with 13a,b are summarized in reaction scheme (7), in which we have used Me₃NO, Me₃SiN₃ and elementary sulfur as oxidants



versus germanium(II). The transient intermediates 14, 15 and 16 behave differently with respect to the ligand at the ring nitrogen atoms. If R = tBu the Ge=X bond is substantially maintained by coordination of the nitrogen base to the electrophilic germanium center (see also lit.) forming 18a and 19a (X-ray structures). If R = SiMe, a migration of the trimethylsilyl group is observed to the electronegative end of the Ge-X-bond while at the same time a SiN2Ge four membered cycle is formed (17b, 18b, 19b). All compounds 12 - 19 show high fluctional mobility as well as a unique stereochemistry at N, Si and Ge.

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